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♥Title: JP59097105A2: INTERFERENCE TYPE POLARIZER

Country: JP Japan

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PInventor: MORI TOSHIO:

PAssignee: SONY CORP

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PApplication
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1982-11-27 JP1982000208063

PAbstract:

PURPOSE: To select a prescribed wavelength according to a polarization plane and to form an interference type polarizer having a simple construction with less occupying space by replacing the dielectric layer of an interference filter with a double refractive dielectric layer obtainable by diagonal vapor deposition.

CONSTITUTION: An interference type polarizer 1 is provided with reflection layers 3, 4 each consisting of a translucent thin film of silver and a double refractive layer 5 formed by diagonal incidence and vapor deposition of a dielectric material, for example, titanium dioxide, on a glass substrate 2. The polarizer 1 constituted in such a way has wavelength selectivity as an interference filter by allowing selective transmission of only the light having the wavelength expressed by $2nd=m\lambda$, where (m) is an integer and (n) is the refractive index of the double refractive layer, with respect to the incident light in a vertical direction on account of the interference effect generated by the thickness (d) of the layer 5. Said polarizer permits also the transmission of the light having a uniform polarization plane and the light having a prescribed wavelength according to the polarization plane of the incident light.

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ਊ Family:

None

Forward References:

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Buy PDF	Patent	Pub.Date	Inventor	Assignee	Title
23	<u>US4813768</u>	1989-03-21	Hamaguchi; Shigeki	Kabushiki	Liquid crystal device have oblique evaporation film protected by a protective



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(54) INTERFERENCE TYPE POLARIZER

(57) Abstract:

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